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APPLICATION NO.	FIL	ING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/739,622	12	2/20/2000	Thomas J.M. Castenmiller	PM 275503 P-0166010 US	4742
909	7590	01/30/2004		EXAM	INER
PILLSBURY P.O. BOX 105		HROP, LLP	HO, ALLEN C		
MCLEAN, VA 22102				ART UNIT	PAPER NUMBER
 .				2882	

DATE MAILED: 01/30/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		UN	
	Application N .	Applicant(s)	
	09/739,622	CASTENMILLER ET AL.	
Office Action Summary	Examiner	Art Unit	
	Allen C. Ho	2882	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet t	vith the correspondence address	
A SHORTENED STATUTORY PERIOD FOR RE THE MAILING DATE OF THIS COMMUNICATIO - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a - If NO period for reply is specified above, the maximum statutory per - Failure to reply within the set or extended period for reply will, by sta - Any reply received by the Office later than three months after the management of the property of the Communication. Status	N. R 1.136(a). In no event, however, may a reply within the statutory minimum of the reply will apply and will expire SIX (6) M6 atute, cause the application to become a second control of the replication of the record of the replication of t	reply be timely filed irty (30) days will be considered timely. NTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133).	
1) Responsive to communication(s) filed on 2	8 October 2003.		
2a)⊠ This action is FINAL . 2b)□ T	his action is non-final.		
Since this application is in condition for allo closed in accordance with the practice under the condition for allo closed.	wance except for formal ma er <i>Ex parte Quayle</i> , 1935 C.	tters, prosecution as to the merits is D. 11, 453 O.G. 213.	
Disposition of Claims	•		
4)⊠ Claim(s) <u>1-16 and 18-35</u> is/are pending in t	he application.		
4a) Of the above claim(s) is/are without	drawn from consideration.		
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-10,12-16 and 18-35</u> is/are reject	ed.		
7)⊠ Claim(s) <u>11</u> is/are objected to.			
8) Claim(s) are subject to restriction an	d/or election requirement.		
Application Papers			
9) The specification is objected to by the Exam	niner.		
10)⊠ The drawing(s) filed on 20 December 2000	is/are: a)□ accepted or b)	☑ objected to by the Examiner.	
Applicant may not request that any objection to	the drawing(s) be held in abey	ance. See 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the cor			
11)☐ The oath or declaration is objected to by the	Examiner. Note the attach	ed Office Action or form PTO-152.	
Priority under 35 U.S.C. §§ 119 and 120			
 12) Acknowledgment is made of a claim for force a) All b) Some * c) None of: 1. Certified copies of the priority docum 2. Certified copies of the priority docum 	ents have been received.		
3. Copies of the certified copies of the papplication from the International But * See the attached detailed Office action for a	oriority documents have bee reau (PCT Rule 17.2(a)).	n received in this National Stage	
13) Acknowledgment is made of a claim for dom- since a specific reference was included in the 37 CFR 1.78.	estic priority under 35 U.S.C first sentence of the specif	C. § 119(e) (to a provisional application) cation or in an Application Data Sheet.	
 a)	estic priority under 35 U.S.C	C. §§ 120 and/or 121 since a specific	
Attachment(s)			
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(5) 🔲 Notice of	Summary (PTO-413) Paper No(s) Informal Patent Application (PTO-152)	

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DETAILED ACTION

Drawings

1. The drawings are objected to under 37 CFR 1.83(a). The drawings must show every

feature of the invention specified in the claims. Therefore, "the three position measuring devices

are arranged orthogonally with respect to each other" as claimed in claim 19 must be shown or

the feature(s) canceled from the claim(s). No new matter should be entered.

In Fig. 2, although each of the position measuring devices 10A and 10B is arranged

orthogonally with respect to the position measuring device 10C, the position measuring devices

10A and 10B are not orthogonal to each other. Accordingly, the objection is being maintained.

A proposed drawing correction or corrected drawings are required in reply to the Office

action to avoid abandonment of the application. The objection to the drawings will not be held

in abeyance.

2. The proposed drawing correction and/or the proposed substitute sheets of drawings, filed

on 16 May 2003 has been approved. A proper drawing correction or corrected drawings are

required in reply to the Office action to avoid abandonment of the application. The correction to

the drawings will not be held in abeyance.

Specification

3. With regard to the amendment filed on 16 May 2003, the objection under 35 U.S.C § 132

has been withdrawn in view of the response from the applicant.

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Claim Objections

4. Claims 27-29 are objected to because of the following informalities: "apparatus" should be replaced by --device-- since they depend on claim 15. Appropriate correction is required.

5. Claims 22, 28, and 34 are objected to because of the following informalities: line 3, "the" in front of "one" should be deleted. Appropriate correction is required.

Claim Rejections - 35 USC § 112

- 6. The following is a quotation of the second paragraph of 35 U.S.C. 112:

 The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 7. Claims 22, 23, 25, 26, 28, 29, 31, 32, 34, and 35 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The applicant fails to claim how the angle is measured. An angle must be defined by two intersecting sides or axes.

Claim Rejections - 35 USC § 103

8. Claims 1-3, 7, 10, 12-16, 22, 25, 28, 31, and 34 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nishi (U. S. Patent No. 5,243,195) in view of Kanaya *et al.* (U. S. Patent No. 5,995,22).

With regard to claims 1-3, 7, 10, 15, Nishi disclosed a lithographic projection apparatus comprising: a projection beam illumination system which supplies a projection beam of radiation (inherent); a first object table (RST) for holding a projection beam patterning device (PA) which

patterns the projection beam according to a desired pattern; a second object table (WST) for holding a substrate (W); a projection system (PL) which images the patterned beam onto a target portion of the substrate; a reference frame (X, Y, Z); and three position measuring devices (IFX, IFY1, IFY2) comprising: three laser sources (inside the interferometer enclosures) mounted on the reference frame (stationary with respect to X, Y, Z), three radiation detectors (inside the interferometer enclosures) mounted in a fixed position on the reference frame (stationary with respect to X, Y, Z), and two mirroring devices (IMX, IMY) mounted on one of the object tables that is movable relative to the reference frame so as to reflect monochromatic collimated laser beams emitted by the laser sources toward the radiation detectors.

However, Nishi failed to teach that the radiation detector is a two-dimensional PSD, or a CCD, or a four-quadrant photo-detector.

Kanaya et al. disclosed a position measuring device that uses a two-dimensional CCD detector for measuring interference fringes.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to employ a two-dimensional CCD for light detection, since a person would be motivated to use a two-dimensional detector to measure the two-dimensional interference fringe patterns produced by the movement of the second object table.

With respect to claims 12, 14 and 16, Nishi disclosed a method of manufacturing a device comprising: providing a substrate (W) provided with a radiation-sensitive layer (column 1, lines 11-16) to a second object table (WST); providing a projection beam of radiation using an illumination system (inherent); patterning the projection beam to form a pattern in its cross section (PA); projecting (PL) the patterned beam onto the target portions of the substrate; and

determining a reference position of the second object table relative to a reference frame (X, Y, Z) by: emitting radiation from a radiation source (IFX, IFY1, IFY2) mounted on the reference frame (stationary relative to X, Y, Z) toward a mirroring device (IMX, IMY) mounted on the second object table, reflecting the radiation, and detecting the reflected radiation in a radiation detector (IFX, IFY1, IFY2) mounted in a fixed position on the reference frame (stationary relative to X, Y, Z).

However, Nishi failed to teach that the radiation detector is a two-dimensional PSD, or a CCD, or a four-quadrant photo-detector.

Kanaya et al. disclosed a position detection device that uses a two-dimensional CCD detector for measuring interference fringes.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to employ a two-dimensional CCD for light detection, since a person would be motivated to use a two-dimensional detector to measure the two-dimensional interference fringe patterns produced by the movement of the second object table.

With regard to claim 13, Nishi in combination with Kanaya et al. disclosed a method according to claim 12, further comprising: determining an absolute position (with respect to the X, Y, Z reference frame) of the second object table by measuring movements thereof relative to the reference position using the incremental position sensing system (IFX, IFY1, IFY2).

With regard to claims 22, 25, 28, 31, and 34, Nishi in combination with Kanaya et al. disclosed that the radiation source and the two-dimension radiation detector are mounted to the reference frame at a predetermined angle relative to the object table (inherent).

Claims 4, 8, 9, 21, 24, 27, 30, and 33 are rejected under 35 U.S.C. 103(a) as being 9. unpatentable over Nishi (U. S. Patent No. 5,243,195) and Kanaya et al. (U. S. Patent No. 5,995,22) as applied to claim 1 above, and further in view of Makinouchi (U. S. Patent No. 5,907,392).

With regard to claims 4, 8, and 9, Nishi in combination with Kanaya et al. disclosed the apparatus according to claim 1, comprising mirroring devices mounted on one of the object tables.

However, Nishi and Kanaya et al. failed to teach or fairly suggest that the mirroring device is a retro-reflector that comprises either a trapezoid form having three mutually perpendicular surfaces meeting at a corner, or a convergent lens and a reflective surface, the reflective surface being spaced a distance from the lens equal to the focal length of the lens.

Makinouchi disclosed an exposure apparatus that uses a retro-reflector (13L, 13R) as a mirroring device mounted on a moving object table.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to employ a retro-reflector that comprises a trapezoid form having three mutually perpendicular surfaces meeting at a corner as a mirror device, since a person would be motivated to use any thing that is functionally equivalent to a mirroring device on one of the object tables. Furthermore, it would have been obvious to a person of ordinary skill in the art at the time the invention was made to choose from among the known equivalents based solely on design choice absent any showing of criticality. The lack of criticality is demonstrated by applicant's claiming of a plurality of equivalent devices.

With regard to claims 21, 24, 27, 30, and 33, Nish in combination with Kanaya *et al.* and Makinouchi disclosed that the mirroring device is configured to reflect the radiation onto a return path parallel to and displaced from in incident path (Makinouchi, Fig. 5).

10. Claims 5 and 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nishi (U. S. Patent No. 5,243,195) and Kanaya *et al.* (U. S. Patent No. 5,995,22) as applied to claim 1 above, and further in view of Tei *et al.* (U. S. Patent No. 6,144,025).

With regard to claims 5 and 6, Nishi in combination with Kanaya et al. disclosed an apparatus according to claim 1, comprising a laser source.

However, Nishi and Kanaya et al. failed to teach or fairly suggest that the laser source comprises a laser diode mountable away from the reference frame, beam-directing optics mountable on the reference frame, and an optical fiber to couple the laser diode to the beam directing optics.

Tei et al. disclosed an interferometer comprising an optical fiber (2) that couples a laser diode (1) to the beam directing optics (3, 4, 5).

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to introduce a laser beam using an optical fiber, since an optical fiber is much more flexible and convenient than optics for introducing a laser beam in a confined area.

11. Claims 18-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yamada et al. (U. S. Patent No. 6,163,369) in view of Kanaya et al. (U. S. Patent No. 5,995,22).

With regard to claims 18-20, Yamada et al. disclosed a lithographic projection apparatus comprising: a projection beam illumination system which supplies a projection beam of radiation (inherent); a first object table for holding a projection beam patterning device (reticle) which

patterns the projection beam according to a desired pattern (column 6, lines 12-15); a second object table (3) for holding a substrate (2); a projection system (1) which images the patterned beam onto a target portion of the substrate; a reference frame (X, Y, Z); and a position system including three position measuring devices (X-interferometer, Y-interferometer, Z-wafer surface position and inclination detection), each position measuring device comprising: a radiation source mounted on the reference frame (lasers 17 in the interferometers and illuminating light source 4), a radiation detector (inherent for interferometers and a two-dimensional radiation detector 11) mounted in a fixed position on the reference frame, a mirroring device (reference mirrors 15 for the interferometers and wafer surface for position and inclination detection) mounted on one of the object tables that is movable relative to the reference frame so as to reflect radiation emitted by the radiation source toward the radiation detector, wherein the position measuring devices are arranged orthogonal to each other.

However, Yamada *et al.* failed to teach that the radiation detector for the interferometer is a two-dimensional PSD, or a CCD, or a four-quadrant photo-detector.

Kanaya et al. disclosed a position detection device that uses a two-dimensional CCD detector for measuring interference fringes.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to employ a two-dimensional CCD for light detection, since a person would be motivated to use a two-dimensional detector to measure the two-dimensional interference fringe patterns produced by the movement of the second object table.

12. Applicant's arguments filed 28 October 2003 have been fully considered but they are not

persuasive.

Applicant argues that Nish's invention uses interferometers, which merely determine a relative change of position of the wafer stage and the reticle stage from a previous position, and they do not measure the position of either the wafer stage or the reticle stage with respect to a reference frame. The examiner does not dispute this statement. However, at some point the absolute position of the wafer stage and the reticle stage must be determined since everything must be measured relative to the reference frame; this is inherent since this is the reason for setting up a reference frame. The examiner never claimed that the interferometers are the position measuring devices; they are merely components of the position measuring devices that

determine the absolute position of the wafer stage and the reticle stage.

Furthermore, applicant argues that there is no motivation for combining Nish and Kanaya et al. The examiner respectfully disagrees. In making the 103 rejections, the examiner never intended to combine the entire subject positioning device of Kanaya et al. with the lithographic projection apparatus of Nishi. The disclosure by Kanaya et al. was only relied upon to teach using a two-dimensional detector such as a CCD for measuring a two-dimensional interference fringe pattern in an interferometer. Therefore, it would have been obvious to a person of ordinary skill in the art to use a two-dimensional detector in Nishi's interferometer to measure a two-dimensional interference fringe pattern produced by a laser beam.

Finally, the examiner would like to reiterate what has been communicated to the applicant in the past office actions. The term "position measuring device" is only a label; it does

not convey or carry any structural limitations. An apparatus claim must be distinguished from the prior art in terms of structure rather than function. See MPEP § 2114.

Allowable Subject Matter

- Claim 11 is objected to as being dependent upon a rejected base claim, but would be 13. allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- Claims 23, 26, 29, 32, and 35 would be allowable if rewritten to overcome the 14. rejection(s) under 35 U.S.C. 112, second paragraph, set forth in this Office action and to include all of the limitations of the base claim and any intervening claims.
- The following is a statement of reasons for the indication of allowable subject matter: 15.

With regard to claims 23, 26, 29, 32, and 35, the prior art fails to teach or fairly suggest that the radiation source and the two-dimensional detector are mounted to the reference frame in such a way that a radiation beam emitted from the radiation source forms a 45° angle relative to either the x or the y-axis of the object table.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this 16. Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO Application/Control Number: 09/739,622 Page 11

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MONTHS of the mailing date of this final action and the advisory action is not mailed until after

the end of the THREE-MONTH shortened statutory period, then the shortened statutory period

will expire on the date the advisory action is mailed, and any extension fee pursuant to 37

CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event,

however, will the statutory period for reply expire later than SIX MONTHS from the date of this

final action.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Allen C. Ho whose telephone number is (571) 272-2491. The

examiner can normally be reached on Monday - Friday from 8:00 am - 5:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Edward J. Glick can be reached at (571) 272-2490. The fax phone number for the

organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is (571) 272-1550.

Allen C. Ho Patent Examiner

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ACH ACH 01.16.04

SUPERVISORY PATENT EXAMINER